



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

August 6, 2026

IGI Report Number

LG824615720

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

OVAL BRILLIANT

Measurements

7.86 X 5.61 X 3.51 MM

GRADING RESULTS

Carat Weight

1.00 CARAT

Color Grade

D

Clarity Grade

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

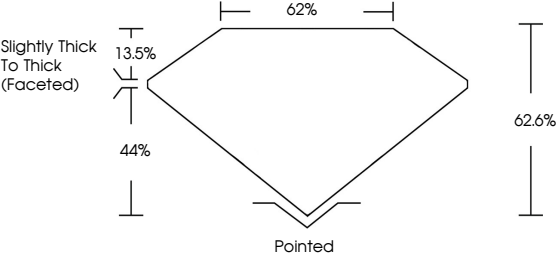
 LG824615720

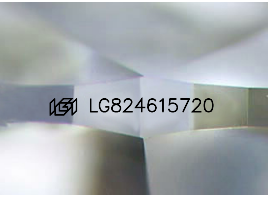
Comments: As Grown - No indication of post-growth treatment.
This Laboratory Grown Diamond was created by High Pressure High Temperature (HPHT) growth process.
Type II

LG824615720

Report verification at [igi.org](https://www.igi.org)

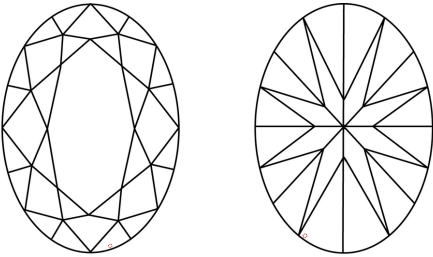
PROPORTIONS





Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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IGI

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OVAL BRILLIANT

7.86 X 5.61 X 3.51 MM

1.00 CARAT

D

VVS 2

62.6%

62%

Slightly Thick To Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

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